

INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Application No.	09/855,321
	Filing Date	May 14, 2001
	First Named Inventor	Suntola, et al.
	Art Unit	1762
(Multiple sheets used when necessary)	Examiner	David Turocy
SHEET 1 OF 1	Attorney Docket No.	ASMMC.013C2

U.S. PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
	1	4,533,820	08-06-1985	Shimizu	
	2	4,689,247	08-25-1987	Doty et al.	
	3	4,836,138	06-06-1989	Robinson et al.	
	4	4,920,918	05-01-1990	Adams et al.	
	5	4,976,996	12-11-1990	Monkowski et al.	
	6	4,993,360	02-19-1991	Nakamura	
	7	5,194,401	03-16-1993	Adams et al.	
	8	5,221,556	06-22-1993	Hawkins et al.	
	9	5,336,327	08-09-1994	Lee	
	10	5,370,738	12-06-1994	Watanabe et al.	
	11	5,695,567	12-09-1997	Kordina et al.	

FOREIGN PATENT DOCUMENTS

Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ¹
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NON PATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ¹
	12	Manual for the F-120 ALE reactor, "F-120 ALE REACTOR SPECIFICATION, Rev. 01", <i>Advanced Thin Film Technology and Surface Chemistry by Atomic Level Control, Microchemistry LTD</i> , 16 pages.	

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Examiner Signature /David Turocy/	Date Considered 04/15/2008
*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

T¹ - Place a check mark in this area when an English language Translation is attached.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /D.T./